

2024 ID5 Joint Statement

The Industrial Design 5 forum (the “ID5”) is a cooperative framework of the five leading IP offices of the China National Intellectual Property Administration (CNIPA), the European Union Intellectual Property Office (EUIPO), the Japan Patent Office (JPO), the Korean Intellectual Property Office (KIPO), and the United States Patent and Trademark Office (USPTO) (the “Partners”). Since its establishment in 2015, the ID5 engages in advancing cooperative activities in areas such as comparative studies of the Partners’ respective industrial design systems and operating practices¹.

Additionally, with the landscape for industrial designs being redefined by new technological environments, such as the metaverse, and developments in generative AI, the Partners recognize the importance of these challenges and will intensify discussions on their impact on the global design system.

In support of these initiatives, the Partners hereby confirm the following as key areas for the ID5 cooperation:

- the Partners will continue outreach and educational initiatives related to the protection of digital designs;
- the Partners will strengthen the exchange of information regarding legal and policy developments in the creation and protection of industrial designs in new technological environments in their respective jurisdictions; and
- the Partners will explore various practices and procedures at each office related to applications filed through the Hague System in order to create more efficiencies for global design applicants.

Through these activities, the Partners, in reinforced collaboration with WIPO, recognize the importance of design protection in the creation of innovative designs, and seek to address the needs of designers in a reliable, transparent, and efficient manner.

¹ Information on the ongoing ID5 projects is available in [the Record of Discussion](#).